

Notice of References Cited	Application/Control No. 10/656,311	Applicant(s)/Patent Under Reexamination CHEN ET AL.	
	Examiner Paul D Kim	Art Unit 3729	Page 1 of 1

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	C	US-5,901,431	05-1999	Santini, Hugo Alberto Emilio	29/603.14
	D	US-5,843,521	12-1998	Ju et al.	428/336
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.